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Submission date: 12-Aug-2024 02:33PM (UTC+0700)

Submission ID: 2426507799

File name: STI_template_13.pdf (3.57M)

Word count: 5100

Character count: 26591

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Nickel Salt Dependency as Catalyst in the Plating Bath on the Film Properties of Cu/Cu-Ni

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Abstract

Metal plating frequently employs nickel (Ni) and copper (Cu) as anodes. Cu/Cu-Ni film formed has many advantages, such as better corrosion resistance and high hardness characteristics. This study aims to assess the properties of Cu/Cu-Ni film, such as phase, surface morphology, crystallographic orientation, hardness, corrosion analysis, and contact angle, which were fabricated using electrodeposition with various Ni salt additions (0.3, 0.5 and 0.7 M). In addition, the cathode current efficiency (CCE) and deposition rate of the Cu/Cu-Ni electrodeposition were also investigated. An increase in Ni salt in the plating bath could enhance the pH, promoting higher CCE and depleting hydrogen evolution at the cathode, leading to the presenting Ni phase in the alloy. The higher concentration of Ni salt in the solution could also enhance the deposition rate due to a shift to a pH value, which affects the roughening of the surface morphology, promoting a higher contact angle. All crystal structures generated by Cu/Cu-Ni electrodeposition were FCC, with the preferred orientation of the (111) plane. Crystallite size and lattice strain depend on the deposition rate. Less crystallite size and lattice strain affect the film's hardness and corrosion resistance. Moreover, the third bath had the resulting Cu-Ni layer with the best hardness and corrosion rate of around 136 HV and 0.081 mmpy.

Keywords

Cathode Current Efficiency, Deposition Rate, Electrodeposition, Corrosion, Hardness

Received: , Accepted:

<https://doi.org/10.26554/sti.2024.9.3.->

1. INTRODUCTION

The electrodeposition procedure is one of the numerous metal coating methods. Metal coating using electrodeposition technology has created many industries that work on coating vehicle engine parts such as pistons, drums, shafts, and other engine parts (Jariwala et al., 2018; Lajevardi et al., 2013). Electrodeposition is done to take advantage of the better properties of the coating element than a substrate. These benefits include heat resistance, a low coefficient of friction, and the prevention of corrosion and erosion properties (Soegijono and Susetyo, 2022; Ghosh et al., 2000; Matsuda et al., 2022). Many factors influence these properties, including solution concentration, temperature, current density, immersion time, pH, and electrical voltage (Kalubowila et al., 2019; Ollivier et al., 2009). Those factors could significantly influence the deposition rate during the electrodeposition process. Moreover, by adjusting

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the deposition rate, structure, grain size, crystallite size, and surface morphology could be controlled (Augustin et al., 2016; Gomez et al., 2005; Rosyidan et al., 2024).

Metals such as copper (Cu) and nickel (Ni) are commonly employed in metal electrodeposition (Hakim and Pangestu, 2022; Setiamukti et al., 2020). Ni is corrosion resistant and has sufficient strength and hardness properties; meanwhile, Cu is a soft and ductile metal that is not too oxidized by air. Cu's reduction potential (+0.34 V) and Ni's reduction potential (-0.25 V) indicate that copper is nobler than Ni. As a result, Cu ions dissolve in solution via diffusion, and Ni ions dissolve via charge transfer (Ghosh et al., 2006; Goranova et al., 2016). Therefore, the concentration of Ni and Cu needs special attention (Ganesan et al., 2022). In addition, a complexing agent is needed to reduce the potential gap between Ni and Cu. Several studies reported the use of pyrophosphate, citrate, acetate, sulfamate, and glycine as complexing agents (Silaimani et al., 2015).

Ghosh et al. (2000) conducted Ni-Cu plating with PC and DC apparatus using bath composition 0.475 M $\text{NiSO}_4 \cdot 7\text{H}_2\text{O}$, 0.125 M $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$, and 0.2 M sodium citrate (pH was maintained using ammonia solution) and resulting corrosion current between 0.17 - 5.77 A cm^{-2} in 3% NaCl, hardness between 384-482 KHN₅₀. Dai et al. (2016) fabricated Ni-Cu film with an electrodeposition technique using 300 g L^{-1} Ni sulfamic acid, 2.5 to 15 g L^{-1} Cu sulfates, 20 g L^{-1} Ni chloride, and 20 g L^{-1} boric acid, resulting in a reduction grain size by increasing Cu content in the alloy. Nady and Nagem (2016) studied the electrodeposition of Ni-Cu alloys using various pH and concentration of NiSO_4 and CuSO_4 , with fixed sodium gluconate boric acid and cysteine at 0.025 A cm^{-2} of current density resulting in mostly FCC (111) and FCC (200) crystal planes of the alloys. Goranova et al. (2016) fabricated Ni-Cu using electrodeposition in 0.2 $\text{C}_6\text{H}_5\text{Na}_3\text{O}_7 \cdot 2\text{H}_2\text{O}$ with different concentrations of Ni salts (0.2, 0.25, 0.5, and 0.6 M $\text{NiSO}_4 \cdot 7\text{H}_2\text{O}$) and 0.1M $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$. The pH (~9) was maintained using a 25% NH_4OH solution. The study found that increasing Ni salt (0.6 M NiSO_4) has a levelling effect.

Unfortunately, presenting a complexing agent could enhance the cost of production of Cu-Ni alloy. Therefore, presenting a Ni salt as a catalyst (without a complexing agent) in the plating bath needs further investigation. This study aims to create a Cu/Cu-Ni alloy on Cu alloy through electrodeposition and investigate the relationship between physical and hardness-corrosion properties. The layers were made using various solutions at 25°C, and then the CCE and deposition rate were investigated. The Cu/Cu-Ni coating underwent characterization for scanning electron microscope-energy dispersive spectroscopy (SEM-EDS), x-ray diffraction (XRD), hardness, corrosion, and water droplets.

2. EXPERIMENTAL SECTION

2.1 Materials and Preparation

Electrodeposition solutions were made using $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$ and $\text{NiSO}_4 \cdot 6\text{H}_2\text{O}$. All chemicals used in the present research are analytical grade from Merck manufacturer. Pure Cu and Ni were used as an anode, while Cu alloy was used as a cathode with chemical compositions of P 0.22 wt.%, Cd 0.684 wt.%, Si 0.137 wt.%, and Cu balance. Before electrodeposition, the cathode was cleaned using ultrasonic cleaner (DELTA D68H) for 5 min. Electrodeposition was performed with a current density of 30 mA/cm^2 for 1 hour at 25°C using a power supply (SANFIX 305 E). The specimens were electrodeposited using various plating baths, as seen in Table 1.

2.2 Characterization

The CCE and deposition rate of the Cu/Cu-Ni electrodeposition were investigated by weighing samples before (initial weight) and after (final weight) electrodeposition and then calculated using equations in the previously reported (Saegjiono and Susetyo, 2022; Rosyidan et al., 2024). Afterward, XRD (PANalytical Aeris with Cu K radiation, $\lambda=0.15418$ nm, step size=0.02°) was used to determine the crystal structure of the

Table 1. Plating Baths Composition for Cu/Cu-Ni Electrodeposition

Plating Bath	Composition (M)		Measured pH
	$\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$	$\text{NiSO}_4 \cdot 7\text{H}_2\text{O}$	
Bath 1	0.1	0.3	2.35
Bath 2	0.1	0.5	2.51
Bath 3	0.1	0.7	2.53

Cu-Ni coating. MAUD software was used to refine and find the crystal parameter using XRD data. Moreover, the Debye-Scherrer formula (Equation 1) was used to calculate the crystal size of various samples (Seakr, 2017).

$$D = \frac{0.9\lambda}{\beta \cos \theta} \quad (1)$$

Where D is the average crystallite size, k is a Scherrer constant of (0.9), λ is radiation wavelength (nm), β is the width of the FWHM diffraction peak (radians), and θ is peak position (° or radians).

FE-SEM equipped with EDS (Thermofisher Quanta 650 EDAX EDS Analyzer) was used to analyze the film surface morphology and phase. Afterward, roughness analysis was performed according to SEM picture using Image J software. Moreover, the hardness of the Cu-Ni film was measured using a MicroMet®5100 Series micro indentation Vickers hardness tester using 100 g of load for 10 s. Measurement was conducted for five spot indentation.

Corrosion investigation was performed using potentiodynamic polarization methods (Digi-Lvy DY2311) in a 3.5% NaCl solution with a volume of 100 ml, the reference electrode being Ag/AgCl and the counter electrode being platinum (Pt) wire. Potentiodynamic polarization was carried out at a speed of 0.002 Vs^{-1} from -1.35 to -0.05 V. Information on corrosion current (i_{corr}) and corrosion voltage (E_{corr}) was acquired from the measurement data using the Tafel extrapolation method. The corrosion rate was calculated using Equation 2 utilizing the corrosion current information (Almad, 2006).

$$\text{Cr} = C \frac{M_{\text{corr}}}{n_f} \quad (2)$$

Where Cr is the corrosion rate (mmpy), C is a constant for the corrosion rate calculation and is 3.27 mmpy, M is the atomic weight (g mol^{-1}), i_{corr} is corrosion current density (A cm^{-2}), n is the number of electrons involved, and p is the density of Cu and Ni (g cm^{-3}). Last step of the samples characterization is measured water contact angle. The contact angle was observed with a water droplet test on the film surface coated. Some criteria of the angle θ were determined by the value as $\theta < 90^\circ$, $90^\circ \leq \theta < 150^\circ$, and $150^\circ \leq \theta < 180^\circ$ for being hydrophilic, hydrophobic, and super hydrophobic, respectively (Lee et al., 2014).

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3. RESULTS AND DISCUSSION

3.1 CCE and Deposition Rate

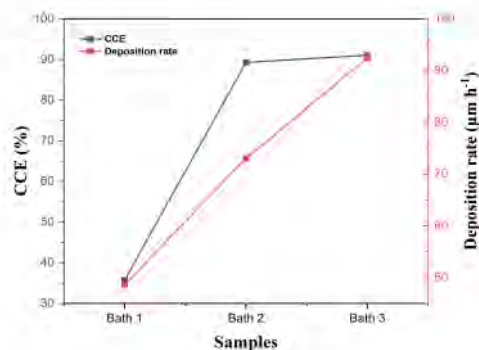


Figure 1. CCE and Deposition Rate for Cu/Cu-Ni Electrodeposited from Bath 1, 2, and 3

Table 2. Average Grain Size Calculation Results of Various Samples

Sample	Grain Size (μm)
Bath 1	105.05
Bath 2	88.22
Bath 3	79.32

Table 3. Average Roughness Value of Various Samples

Sample	Roughness Average (Ra) μm
Bath 1	30.63
Bath 2	37.49
Bath 3	37.82

Table 4. Crystal Parameters of Various Samples

Parameter	Bath 1	Bath 2	Bath 3
Crystal structure	FCC		
Space Group	Fm-3m		
Lattice constant (Å) a = b = c	3.631	3.618	3.612
Cell volume (Å³)	47.89	47.37	47.14
d-spacing (Å)	1.7530	1.7549	1.7578
Crystallite Size (nm)	43.39	27.54	25.70
Lattice strain	0.27	0.41	0.25

The composition of $\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$ and $\text{NiSO}_4 \cdot 6\text{H}_2\text{O}$ was determined at the start of the experiment. Figure 1 shows

Table 5. Corrosion Measurements of Various Samples

Sample	i_{corr} (A cm ⁻²)	E_{corr} (V)	Cr (mmpy)	Criteria
Bath 1	4.40×10^{-6}	-0.261	0.196	Good
Bath 2	5.01×10^{-6}	-0.244	0.223	Good
Bath 3	1.82×10^{-6}	-0.248	0.081	Excellent

the CCE and deposition rate results of various experiments. CCE and deposition rate have similar tendencies; an increase in Ni salt would increase both CCE and deposition rate. CCE refers to the fraction of total current used for metal plating (Rosyidan et al., 2024). At the same time, the deposition rate is the amount of anode material deposited on the cathode at a particular current and time (Park et al., 2008). The first, second, and third solutions had a CCE of 35.71, 89.28, and 91.07%, respectively. The first, second, and third solutions had a deposition rate of 48.66, 72.99, and 92.46, respectively. Hacismailoglu and Alper (2011) have found that increased pH leads to increased transient current. Moreover, Rosyidan et al. (2024) have seen that an increase in the current leads to a rise in CCE and deposition rate. Therefore, increased Ni salt promotes increased CCE and deposition rate due to rise and pH (see Table 1).

Hydrogen evolution could happen at the cathode when electrodeposition is conducted. Hydrogen evolution could disruption's movement to the substrate's surfaces during deposition by blocking the cathode surface. Deo et al. have stated that hydrogen evolution is a competitor at Ni and Cu electrodeposition (Deo et al., 2020). According to the CCE result, higher hydrogen evolution occurred in the samples made using the first solution, and increasing a Ni salt in the solution led to a decrease in hydrogen evolution. Güler et al. (2013) have stated that presenting a hydrogen evolution at the cathode during electrodeposition leads to a decrease in CCE.

3.2 Phase and Surface Morphology

In this study, film deposition involved diffusion and charge transfer by Cu/Cu-Ni. The various films were obtained using a current density of 30 mA cm^{-2} for an hour for all solution variations. The results of the EDS investigation can be seen in Figure 2. Based on Figure 2, it can be seen that 100 wt.% Cu phases are seen when electrodeposited using baths 1 and 2. This means presenting a Ni salt 0.3 and 0.5 M doesn't cause an exhibit of Ni in the film. Meanwhile, when Ni salt concentration rises to 0.7 M, Ni is exhibited in the film around 0.2 wt. %. The solution seems to have a salt limitation, resulting in a Cu-Ni Alloy. Decrease a Cu salt by less than 0.1 M or increasing a Ni salt by more than 0.7 M is needed. Baskaran et al. (2006) electrodeposited Ni using the composition between Ni and Cu salt, which is 20:1. Sarac et al. (2012) electrodeposited Ni using the composition between Ni and Cu salt are 50:1. Moreover, Hacismailoglu and Alper (2011) have stated that hydrogen evolution was occurring at the surface of the substrate during the electrodeposition process, which could prevent the

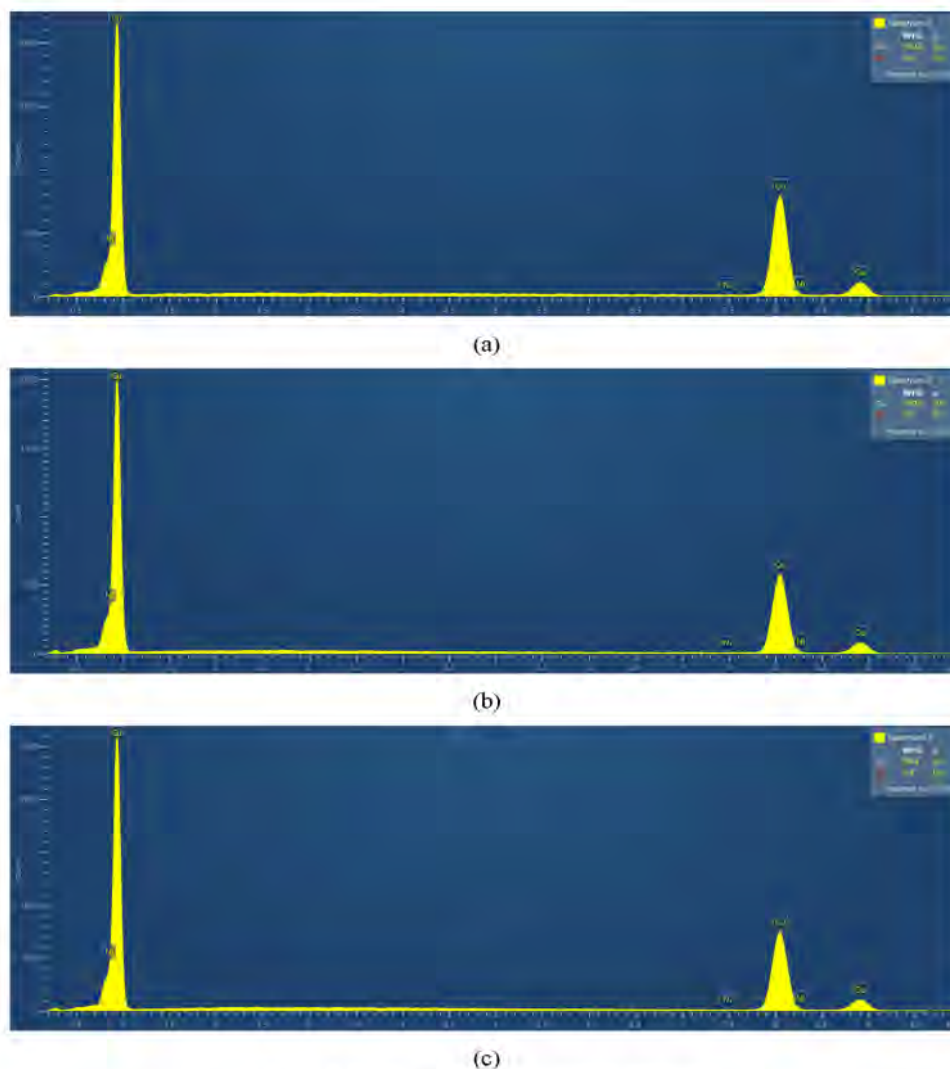


Figure 2. EDS Test Results of Various Samples

reduction of Ni in the film. This statement is corroborated by the fact that Ni formed in the sample was made using a third solution due to electrodeposition using the first and second solutions, which still caused hydrogen evolution on the substrate surface.

Figures 3 (a)-(c) show the morphology of the deposited non-uniform and compact films, which is affected by the hydrogen evolution. Güler et al. (2013) have stated the disruption is due to hydrogen evolution at the cathode, which could be resulting a non-uniform film. Moreover, pure Cu (Figures 3 (a) and (b)) show morphology with nodules form. In contrast, presenting a Ni in the alloy, which changes nodules to a cauliflower-like form (Figure 3 (c)). As mentioned above, exhibiting a Ni salt

in the solution could increase the pH of the solution (Table 1). Kalubowila et al. (2019) have found that increasing the pH bath could transform surface morphology. Furthermore, raising a pH solution leads to an increased deposition rate and change in surface morphology. Therefore, there is transformation from nodules to a cauliflower-like form. Statistical analysis using Image J combined Origin with the corresponding Gauss fitting function was used to identify the grain size distribution. The result is presented in Figure 3.

Image J software was used to calculate the average grain size diameter. Table 2 shows the results of calculating the average grain size. The calculation results show that the grain size average has decreased by increasing the Ni salt in the solution.

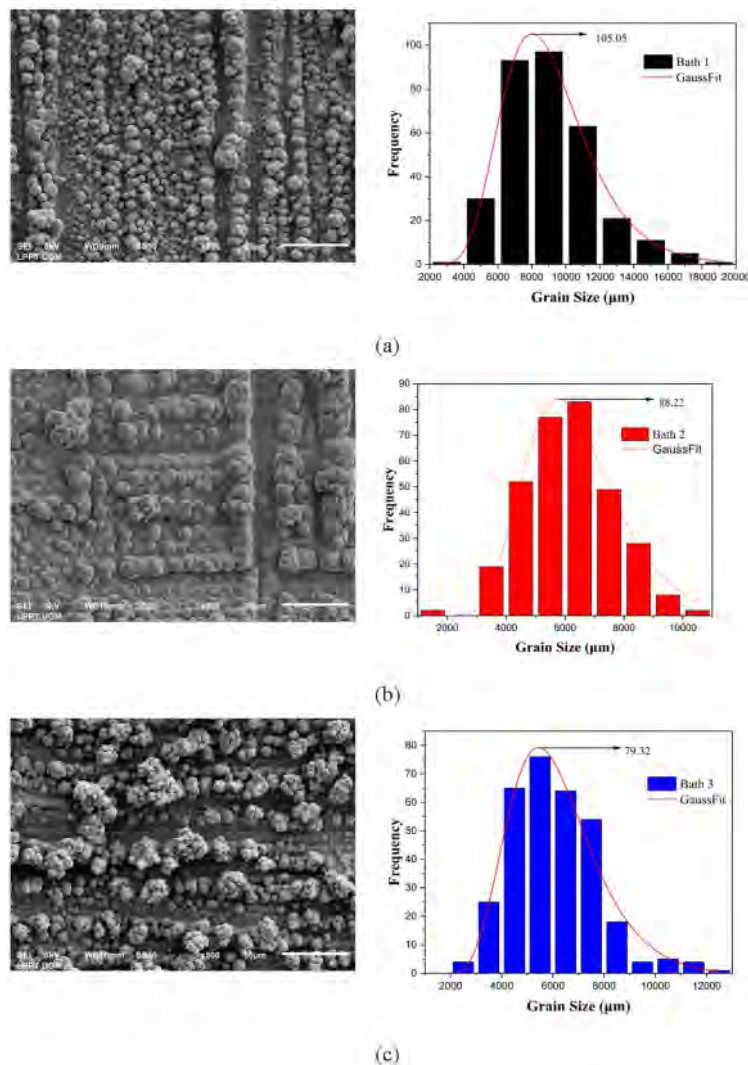


Figure 3. SEM Micrographs and Grain Distribution for Different Samples (a) Bath 1, (b) Bath 2, and (c) Bath 3

Baskaran et al. (2006) stated that grain size decreased due to increased electrodeposition current density. Previous research shows that increasing current density increases deposition rate (Rosyidan et al., 2024). Compared to Figure 1, it is seen that rising Ni salt leads to an increased deposition rate. An increase in the deposition rate leads to an increased speed of the ion species deposited on the cathode surface. Therefore, grain size is decreasing in the present research.

Image processing was done using Image J software to obtain detailed information about the resulting image pattern. Image patterns were investigated from SEM pictures to interpret the results of surface roughness parameters and 3-D images from surface scanning. The result of the Image J software investiga-

tion can be seen in Figure 4, which presents the relationship between distance (μm) and gray value varies with increasing distance.

Table 3 shows the average surface roughness of Cu-Ni/Cu coating morphology fabricated from various baths according to Image J software investigation. According to Table 3, increasing Ni salt in the solution increases the films' roughness average. Deo et al. (2020) reported that increasing a current density led to an increase in surface roughness. As mentioned above, increasing current density increases deposition rate (Rosyidan et al., 2024). Compared to the deposition rate measurement (Figure 1), it can be seen that rising Ni salt leads to an increased deposition rate due to pH increments. An increase in the

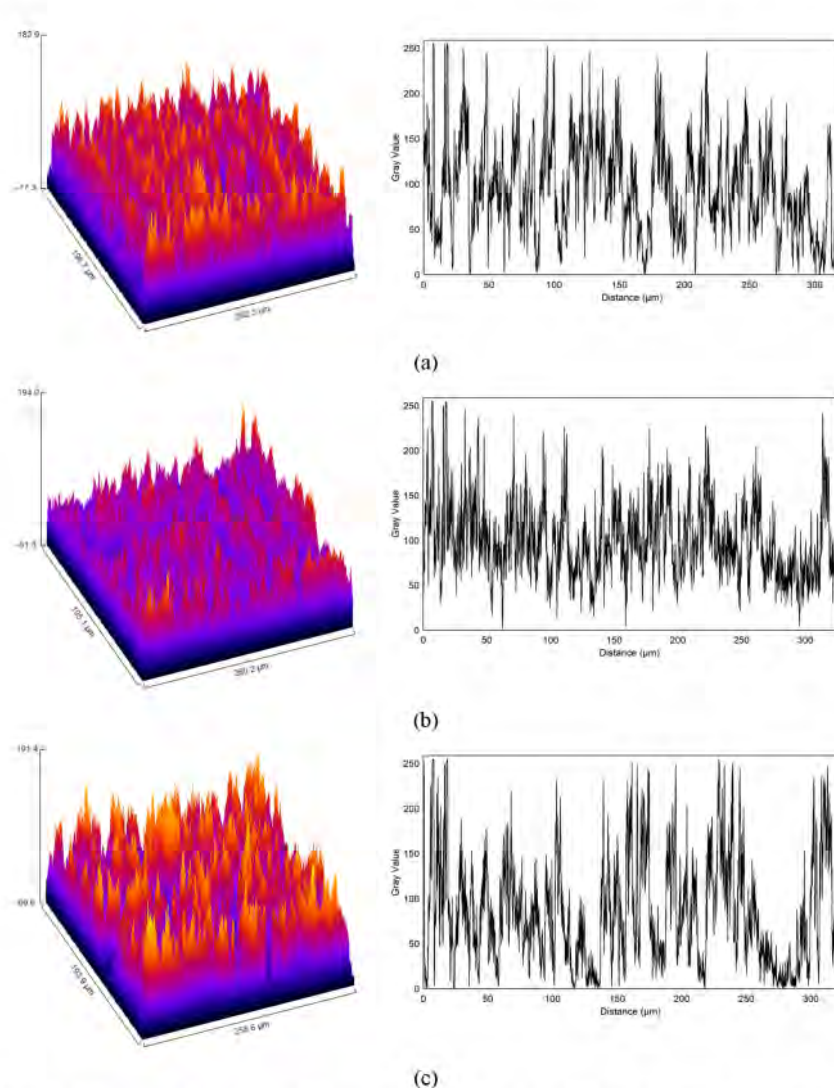


Figure 4. Analysis of Sample Surfaces Roughness in 3D SEM Image and Graph of Grey Value Against Distance (Left-Right) (a) Bath 1, (b) Bath 2, and (c) Bath 3

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deposition rate leads to an increased speed of the ion species deposited on the cathode surface. Therefore, the roughness average is increased in the present research.

3.3 Crystallographic Orientation

According to the XRD data in Figure 5, three planes formed namely the (111), (002), and (022) planes. The (111) plane dominated when the films were made using baths 1, 2, and 3. The dominance of the (111) plane orientation had benefits such as anticorrosion, increased electrical conductivity, and improved mechanical properties (Seakr, 2017). Moreover, all of the collected XRD data were then analyzed using MAUD

software, and the crystal parameters are shown in Table 4. All led to the same crystal structure and space group, FCC and Fm-3m, which can be concluded that atoms of the Cu and Ni form a substitutional solid solution (Dai et al., 2016).

Table 4 shows that the lattice constant and cell volume decrease due to the increase in the Ni phase in the alloy, which perfectly agrees with other reports (Baskaran et al., 2006). Moreover, increased Ni salt in the plating bath decreases crystallite size. Augustin et al. (2016) have reported an increase in current density promoting reduced crystallite size. Increasing the electrodeposition process's current density influences the deposition rate's increase; the amount of ion species deposited

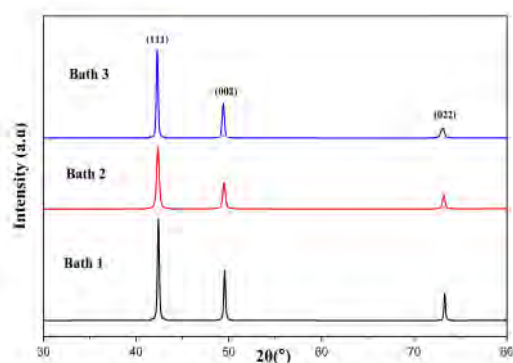


Figure 5. XRD Pattern of Various Samples

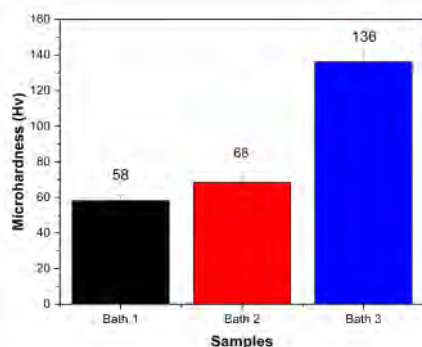


Figure 6. Hardness Test Results of Various Samples

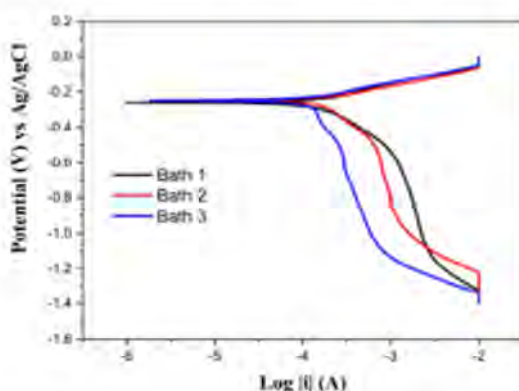


Figure 7. Corrosion Curve for Various Samples

on the cathode rose; therefore, crystallite size decreased. Small crystal size indicates that the distance between grains is close, contributing to material qualities with more roughness proper-

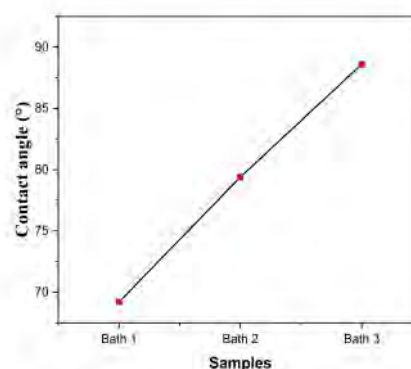


Figure 8. Water contact angle of various samples

ties (Dai et al., 2016). This result is in perfect agreement with the average roughness in Table 3. Moreover, a smaller lattice strain is seen in the sample made using bath 3.

3.4 Hardness

Hardness is a material's resistance to plastic deformation. A coating procedure is considered successful if it can enhance the qualities of the coated objects. One of the purposes of electrodeposition in the present research is to improve material deposited hardness. The results of the hardness of the coating were obtained using a Vickers micro-hardness tester. The Vickers microhardness method obtained 58 HV in the first solution, 68 HV in the second solution, and 136 HV in the third solution. It seems an increase in Ni salt would increase the hardness. In their study, Augustin et al. found that a decrease in crystallite size promotes an increase in hardness, which is in perfect agreement with the present research (Augustin et al., 2016). Besides crystallite size, the exhibit of Ni in the alloy also influences the hardness of the sample (Rosyidan et al., 2024). As seen in Figure 6, a sample was made using bath 3, resulting in higher hardness, which is affected by the exhibit of Ni in the alloy. According to the EDS result, only one sample was made using bath 3, resulting in Ni in the alloy. Compared to the Monel 400, hardness is between 150 to 200 HV, and present research has lower hardness (Kuklinski et al., 2020).

3.5 Corrosion

Figure 7 shows the corrosion curves of the electrodeposition of Cu/Cu-Ni on the Cu alloy substrate. The i_{corr} and E_{corr} were found using the Tafel extrapolation method. Meanwhile, CR was calculated using Equation (2). The summary of the calculations for the CR of various samples is shown in Table 5. The crystal plane could determine the corrosion rate behavior of materials with the FCC crystal system. The (111) crystal plane is more corrosion-resistant in materials with the FCC system than the (002) and (022) crystal planes (Al Khwarafi et al., 2012). Therefore, all of the samples met good and excellent

criteria. Moreover, based on Table 5, it can be seen that the third solution has the best corrosion rate. This behavior is influenced by the lattice strain that was formed. Lattice strain is sample defect concentration measured due to a void core in the lattice (Basori et al., 2023). Therefore, the smallest lattice strain leads to the highest corrosion resistance. According to Wang et al. and Ghosh et al. studies, Monel-400 i_{corr} is 2.24×10^{-6} and 2.2×10^{-6} ($A\ cm^{-2}$) (Ghosh et al., 2000; Wang et al., 2014). Compared with Table 5, it can be seen that the sample made using a third solution has lower i_{corr} than Monel-400.

3.6 Contact Angle

The water droplet test can be used to determine the hydrophilic, hydrophobic, and superhydrophobic properties of a film. Figure 8 shows a snapshot of the drip test findings for various samples. All samples possess hydrophilic properties since they have contact angles between 0° and 90° (Thurber et al., 2016). The contact angles achieved in the first, second, and third solution 1 are 69.2° , 79.4° and 88.6° , respectively. Increment of the water contact angle is probably due to an increased film surface roughness. In their research, Huang et al. found that increasing roughness would increase the water contact angle (Huang and Gates, 2020). Moreover, Yu et al. found that increasing electrolyte pH from 2 to 4 increases the film's water contact angle (Yu et al., 2013), probably due to an increase in the surface roughness of the samples.

4. CONCLUSION

Cu/Cu-Ni film was electrodeposited onto Cu alloy using various bath compositions, and according to the multiple findings, increased Ni salt content led to increased deposition rate and CCE due to an increased pH and depleting hydrogen evolution, which impacted grain size, more roughness, less crystallite size and presenting small amount of a Ni in the film. The formed crystal structure was a single-phase FCC with the dominant (111) plane. The hardness increment is due to a decrease in crystallite size. Lesser lattice strain contributed to a higher corrosion resistance. The films have more roughness and impact on the higher water contact angle. The 99.8Cu0.3Ni alloy has the best corrosion resistance and is recommended as an alternative to change Monel-400.

5. ACKNOWLEDGMENT

This project was financially supported by Universitas Trisakti based on the assignment letter number 800/C-4/FTKE/USA KTI/X/2023.

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